Notice of Allowability	Application No.	Applicant(s)
	10/697,837	RUDECK ET AL.
	Examiner	Art Unit
	Toniae M. Thomas	2822
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. X This communication is responsive to the amendment filed on 27 May 2005.		
2. The allowed claim(s) is/are <u>1-17</u> .		
3. X The drawings filed on 28 October 2003 are accepted by the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient. 6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted. (a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d). 7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL. 		
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Summary Paper No./Mail Dat 98), 7. ☐ Examiner's Amendr	te

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Reasons for Allowance

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The following is an examiner's statement of reasons for allowance: the prior art of record does not anticipate, teach or suggest a method used during the formation of a semiconductor device, the method comprising the steps substantially as claimed. For example, the Hsue et al. patent - US 5,115,296 (Hsue), which was relied upon in the Office action mailed on 25 February 2005, discloses a method used during the formation of a semiconductor device to simultaneously oxidize a first semiconductor region and a second semiconductor region by exposing the first and second regions to an oxidizing atmosphere. However, Hsue does not anticipate, teach or suggest exposing the first and second semiconductor regions to an oxidizing ambient which comprises a volumetric ratio of H₂O to H₂ gas of between 0.05 to about 0.15, as recited in claims 1, 13, and 17. The prior art of record does not teach or suggest the modification of Hsue by exposing the first and second semiconductor regions to an oxidizing ambient which comprises a volumetric ratio of H₂O to H₂ gas of between 0.05 to about 0.15. Moreover, the prior art of record does anticipate, teach or suggest a method for forming a flash memory device including a transistor substantially as claimed, wherein the method comprises exposing a source region and a drain region of the transistor to an oxidizing ambient which oxidizes the source region at a faster rate than the drain region, as recited in claim 5.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toniae M. Thomas whose telephone number is (571) 272-1846. The examiner can normally be reached on Monday through Friday from 8:30 a.m. to 5:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on (571) 272-1852. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TMT 11 June 2005

> Mary Wilczewski Primary Examiner